**R09** 

## Code No: C5710 JAWAHARLAL NEHRU TECHNOLOGICAL UNIVERSITY HYDERABAD M.Tech I Semester Examinations March/April-2011 MICRO ELECTROMECHANICAL SYSTEMS (VLSI SYSTEM DESIGN) Time: 3hours Max.Marks:60

## Answer any five questions All questions carry equal marks

- 1. Give an overview of MEMS manufacturing process and state how Micro electro mechanical systems (MEMS) responds to pressure input. [12]
- 2. a) Define the terms stress, strain, bending moment, deflection curve.
  b) What is meant by distribution force and how can the distribution force effect the MEMS. [12]
- 3. Using the Laplace transformation derive the filed for critical fringe field. [12]
- 4. Write a brief note on two terminals and three terminal MEMS structure. Also state the advantage of one over the other. [12]
- 5. Discuss in detail the MEMS application in frequency converters, wave shaping and RF Switches for modulation. [12]
- 6. Describe the process of using MEMS for measurement of at least four non electrical quantities. [12]
- 7. Write a brief note on silicon based MEMS's process flow. [12]
- 8. Write a brief note on Thin and thick film technologies for MEMS. [12]

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